ingemengangan inge

-	1	1	
	Prasad R Akkapeddi	2871	
The MAILING DATE of this communication appears All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOT of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this apport or other appropriate communication IGHTS. This application is subject to	plication. If not include will be mailed in due	ed course. THIS
1. This communication is responsive to <u>01/20/2004</u> .			
2. The allowed claim(s) is/are <u>1-19</u> .			
3. The drawings filed on 17 November 2000 are accepted by	the Examiner.		
 4. Acknowledgment is made of a claim for foreign priority una a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 	been received. been received in Application No cuments have been received in this of this communication to file a reply	national stage applica	
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give			OTICE OF
6. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the	on's Patent Drawing Review (PTO- s Amendment / Comment or in the C .84(c)) should be written on the drawing the header according to 37 CFR 1.121(c	office action of ngs in the front (not the	
 DEPOSIT OF and/or INFORMATION about the depo- attached Examiner's comment regarding REQUIREMENT 	sit of BIOLOGICAL MATERIAL n FOR THE DEPOSIT OF BIOLOGIC	nust be submitted. N AL MATERIAL.	lote the
 Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date	5. ☐ Notice of Informal P 6. ☐ Interview Summary Paper No./Mail Dat 8), 7. ☐ Examiner's Amendn 8. ☑ Examiner's Stateme 9. ☐ Other	(PTO-413), e nent/Comment	

DETAILED ACTION

Response to Arguments

1. Applicant's arguments, see amendments to claims, filed 01/20/2004, with respect to claims 1-19 have been fully considered and are persuasive. The rejection of 10/20/2003 has been withdrawn.

Allowable Subject Matter

- 2. Claims 1-19 are allowed.
- 3. The following is an examiner's statement of reasons for allowance:

A search of the prior art did not disclose a method of filling a liquid crystal material into a liquid crystal panel and a system of filling a liquid crystal material into a liquid crystal panel comprising a combination of structural elements, more specifically:

- (a) Preparing an <u>indentation (113) that is indented from a side of the lower</u>
 <u>substrate</u> to the injection port (see Fig. 7 of the instant application).
 - (b) Inserting the protruded portion of a tray into the injection port and
- (c) Introducing the liquid crystal material into the liquid crystal panel through the protruded portion and the injection port.

The uniqueness of the invention is in the indentation on the lower substrate. Conventional techniques of filling the liquid crystal material, as taught by the following references, include a lower substrate and an upper substrate, a seal in between the two substrates having an injection port. The two substrates

are then attached and brought into contact with a reservoir containing the liquid crystal material. The liquid crystal material then fills the panel via capillary action.

- (a) Inoue et al. (U.S.Patent No. 6,285,435) discloses two flat substrates (210 and 202) with a seal (203) having an injection port (203a) (Fig. 15).
- (b) Nakamura et al. (U.S.Patent No. 5,835,181) also teaches that the substrates (11 a and 11b) with a seal (10) having an injection port (12) (Fig. 9).
- (c) Yokoyama et al. (U.S.Patent No. 5,751,391) also teaches a pair of substrates with a seal (11) and an injection port (2) (Fig. 6).
- (d) Yoshida et al. (U.S.Patent No. 5,583,671) also teaches a pair of substrates (1 and 2) with a seal (3) and an injection port (3a) (Fig. 6A).

Hence, none of the prior art including the ones cited earlier teaches an indentation in the lower substrate that is indented to the injection port.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Prasad R Akkapeddi whose telephone number is 571-272-2285. The examiner can normally be reached on 7:00AM to 5:30PM M-Th.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robert H Kim can be reached on 571-272-2293. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

PRA

Prasad R Akkapeddi, Ph.D Examiner Art Unit 2871

DUNG T. NGUYEN
PRIMARY EXAMINER